

Conference Information

DATE: Oct. 22~27, 2023

VENUE: Hwabaek International Convention Center (HICO)

*** SCIENTIFIC PROGRAMS**

- Residual Stress & Process Performance
- Fatigue Life Extension
- Shock Waves & Process Visualization Methods
- Process Modeling & Simulations
- Material Hardening & Microstructural Characterization
- Innovative & Alternative Laser Peening Applications
- Related Phenomena
- Laser Peening For High Strength & Alternative Materials
- Surface Modifications
- Development of Commercial Laser Peening Systems / UNSM Systems / Cavitation Peening Systems / Water Jet Peening System / Ultrasonic Peening Systems, etc.
- Laser Peen Forming and Other Novel Processes
- Special Sessions and Poster Sessions

*** PUBLICATIONS**

- Conference Proceedings
- Selected articles in the special issue of METAL (IF: 2.695, MATERIALS (IF: 3.68) (SCIE, SCOPUS)
- Selected articles in the special issue of International Journal of
- Precision Engineering and Manufacturing (SCIE, SCOPUS, IF:2.04)
- Potential journals by MDPI, Elsevier, etc.

*** EXHIBITION**

- Processing device and application samples
- Residual stress measuring device, High cycle fatigue testing device, etc.

REGISTRATION FEES

Participant Type	Early Bird	Regular
Regular	USD 600	USD 700
Postdoctoral	USD 500	USD 600
Student	USD 400	USD 500
Accompanying Person	USD 100	USD 100

- The 8th ICLPRP in Shanghai, China has been canceled due to COVID19 and has been transferred into Gyeongju, Korea
- The 8th ICLPRP will be co-hosted with the 2023 fall conference of the Korean Nuclear Society
- Co-organized several joint sessions and a workshop with the Korean Society of Mechanical Engineers

Technical Tour



Important Due Date

- Abstract(title and 200 words) Due: April 30, 2023 (option: oral or poster choice)
- Notification of Acceptance : May 15, 2023
- Early Registration Due : Aug. 1, 2023 (option: publication journal selection)
- Registration Desk Open at Venue : From 3PM, Oct. 22, 2023



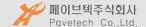




















HICO, Gyeongju